



Slow Down Regenerative Mask
II-44.110.01A

<i>Phase</i>	<i>Material Name</i>	<i>US INCI</i>	<i>Supplier</i>	<i>% Material</i>
A	Deionized Water	Water	N.A.	84.84
A	Zemea	Propanediol	DuPont Tate & Lyle	4.00
A	MultiMoist CLR™	Fructooligosaccharides Beta Vulgaris (Beet) Root Extract Water	CLR	3.00
A	Euxyl K 900	Benzyl Alcohol Ethylhexylglycerin Tocopherol	Ashland	0.55
B	Carbopol Ultrez 30	Carbomer	Lubrizol	0.75
C	NaOH (32%)	Water Sodium Hydroxide	N.A.	0.61
D	AnnonaSense CLR™	Annona Cherimola Fruit Extract	CLR	3.00
D	ProRenew Complex CLR™	Lactococcus Ferment Lysate	CLR	3.00
E	Perfume Black Bamboo WS	Fragrance	Voegele	0.25
				100.00

Operating Instructions

Mix A and stir until uniform. Sprinkle B into A and wait 15-30 minutes. Adjust pH value to 5.5 with C. Add D while stirring. Add E as desired and stir until homogeneous.

Directions for use:

Apply the mask on cleansed skin generously. Leave-on for 10-15 minutes and massage into skin.

The recommendations and formulations given are based on our knowledge and experience in the field of technical application.

They are, to the best of our belief, correct, but are offered without obligation.

Those who use our recommendations and formulations as well as those who process CLR Active Agents are themselves responsible for the adherence to prevailing statutory regulations and the observance of patent rights as well as other protective rights for other companies.

This formula has been manufactured and stability-tested using a special preservative, but has not been subjected to microbiological challenge tests.

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